

EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S175	395	(silicate or perovskite) near10 (ald or ale or alcvd or atomic near2 layer near2 (epitax\$5 or deposit\$5 or chemical near2 vapor near2 deposit\$5))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:21
S174	130	(ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale) same (multi \$1compon\$7)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:21
S173	6159	S172 same ("sio. sub.2" or silicon near2 (dioxide or oxide))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:21
S172	35899	ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:21
S177	2049	(ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale) near20 ("sio.sub.2" or sio2 or silicon near2 oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:22
S176	174	S172 same (oxide near10 (binary or tertiary))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:22

S179	29	(ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale) near20 ("sio.sub.2" or sio2 or silicon near2 oxide) and "117"/\$. ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:23
S178	117	(eva near2 tois or suvi near2 haukka or marko near2 tuominen).in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:23
S181	10	(ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale) and matt\$5 near2 song	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:27
S180	0	(ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale) same (multi \$1compon\$7) and matt\$5 near2 song	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/07/13 04:27

EAST Search History (Interference)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S182	44	(ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale) same (multi \$1compon\$7)	USPAT; UPAD	OR	ON	2010/07/13 04:21
S183	791	(ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale) near20 ("sio.sub.2" or sio2 or silicon near2 oxide)	USPAT; UPAD	OR	ON	2010/07/13 04:22

S185	54	(atomic near2 layer near2 (deposit\$5 or epitax\$6)) near5 silicate	USPAT; UPAD	OR	ON	2010/07/13 04:24
S184	791	(ald or atomic near2 layer near2 (epitax\$5 or deposit\$5) or ale) near20 ("sio. sub.2" or sio2 or silicon near2 oxide)	USPAT; UPAD	OR	ON	2010/07/13 04:24

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